## Amendments to the Specification:

Please replace the paragraph beginning on page 24, line 24, with the following rewritten paragraph:

Note that the configuration of the twin stage type exposure apparatus is not limited to the type of this embodiment. For example, they are disclosed in Japanese Unexamined Patent Application, first Publication No. H10-163099, Japanese Unexamined Patent Application, first Publication No. H10-214783 and U.S. Patent No. 6,400,441 corresponding thereto, Published Japanese Translation No. 2000-505958 and U.S. Patent No. 5,699,441–5,969,441 and U.S. Patent No. 6,262,796 corresponding thereto.